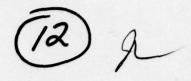


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Task No. NR 056-573

TECHNICAL REPORT No. 9

Ultraviolet Photoemission Studies of Formaldehyde and Related Molecules Adsorbed on Ru(110)

by

Galen B. Fisher, Theodore E. Madey and John T. Yates, Jr.

Preprint of Publication

in

Journal of Vacuum Science and Technology

National Bureau of Standards
Surface Processes and Catalysis Section
Washington, DC 20234

December 15, 1977

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9. PERFORMING ORGANIZATION NAME AND ADDRESS	10. PROGRAMMILEMENT PROJECT, TASK
Surface Processes and Catalysis Section	61153N, RR Ø13-Ø8
National Bureau of Standards	RR 013-08-01, NR 056-573
Washington, DC 20234	
11. CONTROLLING OFFICE NAME AND ADDRESS	DE. REPORT DATE
Office of Naval Research Chemistry Program Office (Code 472)	December 1977
Rm 624, 800 No. Quincy St., Arlington, VA 22217	
14. MONITORING AGENCY NAME & ADDRESS(If different from Controlling Office)	15. SECURITY CLASS. (of this report)
(K) NED (M)	Unclassified
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To appear in the Proceedings of the 24th A.V.S. National Symposium, Boston, 1977; J. Vac. Sci. Tech., Volume 15, March/April, 1978.

ULTRAVIOLET PHOTOEMISSION STUDIES OF FORMALDEHYDE

AND RELATED MOLECULES ADSORBED ON Ru(110)
Galen B. Fisher, Theodore E. Madey, and

John T. Yates, Jr.

National Bureau of Standards
Washington, DC 20234

ABSTRACT

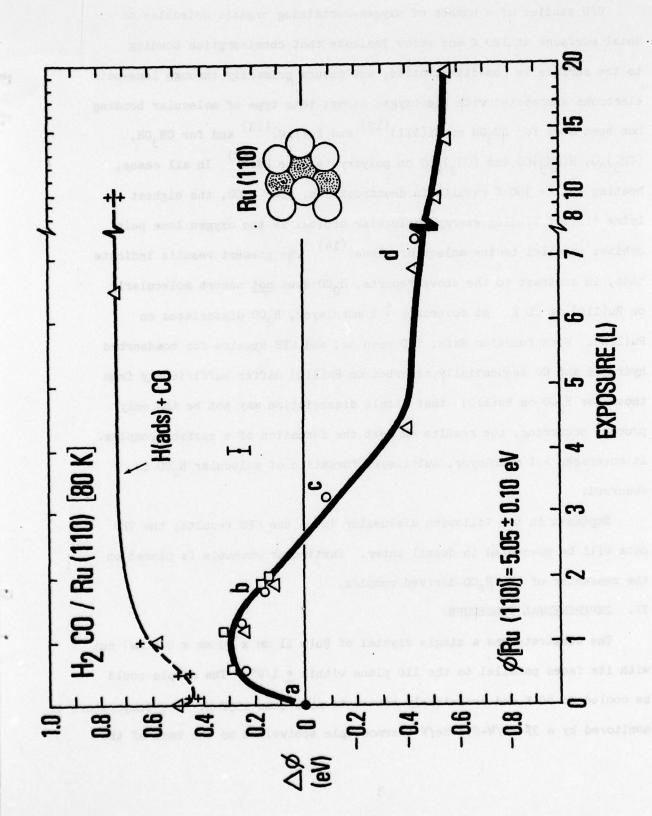
The adsorption of formaldehyde (H₂CO), hydrogen, and carbon monoxide on Ru(110) has been studied using angle-integrated ultraviolet photoemission spectroscopy (UPS) and temperature programmed desorption (TPD). The UPS spectra for low exposures of H₂CO at 80 K indicate that H₂CO dissociates to a substantial degree. These spectra are compared with UPS spectra for the sequential adsorption of hydrogen and CO. Whereas there are similarities between these spectra, the differences in the UPS, work function change, and TPD results are sufficient to suggest that a portion of the dissociated H₂CO may exist as a surface molecular complex containing H and CO. This is apparently the first reported example, based on a UPS study, of an oxygen-containing organic molecule which dissociates upon adsorption on a metal surface at 80 K. For high exposures at 80 K, adsorption of a condensed layer of molecular H₂CO is observed.

I. INTRODUCTION

The adsorption of small organic molecules on surfaces is of importance in a variety of areas including catalysis, electronic devices, and lubrication. An important energy-related catalytic process is the methanation reaction $(3H_2 + CO + CH_4 + H_2O)$ which is used in the production of synthetic natural gas; one of the most active catalysts for this reaction is ruthenium. (1,2) Although the detailed mechanisms of the reaction are not known, it has been suggested that methanation proceeds via the formation of H_2CO or H_2CO -derived intermediates. (1) Recent Temperature Programmed Desorption studies (TPD) of H_2CO adsorbed on the $Ru(110)^{\#}$ surface at 300 K demonstrate that small quantities of CH_4 are produced as a decomposition product. (3,4) In the present effort, we have used Ultraviolet Photoemission Spectroscopy (UPS) and TPD to characterize the adsorption and decomposition of H_2CO on Ru(110) at $T \sim 80$ K; the atomic structure of the ideal Ru(110) surface is shown in the inset to Fig. 1.

In previous UPS studies, molecular H_2 CO adsorption has been reported at $\sim 80 \text{ K on ZnO}^{(5)}$ and MoS_2 surfaces.}^{(6)} H_2 CO has been reported to decompose on Pd films at 300 K, $^{(7)}$ and to form molecular multilayers on polycrystalline Pd at 120 K. $^{(5)}$ During thermal desorption studies of the decomposition products of H_2 CO on Pd at T > 300 K, an attractive interaction between H(ads) and H_2 CO on Pd at T > 300 K, an attractive studies of H_2 CO adsorption have been on W surfaces. $^{(9-11)}$ On W(100) at 300 K, adsorption appears to be dissociative at low coverages, but a molecular complex is present at higher coverages ($\theta \sim 1 \text{ monolayer}$) as evidenced by TPD, $^{(9)}$ UPS, $^{(10)}$ and XPS $^{(11)}$ (X-ray Photoelectron Spectroscopy). Adsorption of H_2 CO on W(100) at $\sim 80 \text{ K}$ results in formation of a molecular complex as well as non-dissociatively adsorbed H_2 CO. $^{(11)}$ To the best of our knowledge, there have been no previous *We use the three-digit notation for the hexagonal crystal rather than the redundant four digit notation in which this face would be denoted (1120).

Fig. 1. Lower curve: work function change, Δ¢, as a function of H₂CO exposure on Ru(110) at 80 K. (1 L = 1 Langmuir = 1 x 10⁻⁶ Torr-sec.; 1 Torr = 133.3 N/m²). Data from separate data runs are indicated by different symbols. The measurement uncertainty is indicated by the error bar in the center of the figure.
Upper curve: work function change, Δ¢, as a function of CO exposure on Ru(110) which was pre-covered by a monolayer of hydrogen; T = 80 K. Present measurements are shown as triangles; the crosses indicate the unpublished data of Sandstrom, et al. (Ref. 18). An inset at the right is a schematic of the atomic arrangement of the ideal Ru(110) surface.



published UPS studies of the adsorption of fractional monolayers of ${\rm H_2CO}$ on clean metal surfaces at T \sim 80 K.

UPS studies of a number of oxygen-containing organic molecules on metal surfaces at 120 K and below indicate that chemisorption bonding to the surface is non-dissociative, and occurs primarily through lone-pair electrons associated with the oxygen atoms; this type of molecular bonding has been seen for CH_3OH on $Ni(111)^{(12)}$ and $Ru(110)^{(13)}$ and for CH_3OH , (CH₃)₂O, H(CH₃)CO and (CH₃)₂CO on polycrystalline Pd. (7) In all cases, heating to T > 300 K results in decomposition. For H2CO, the highest lying (lowest binding energy) molecular orbital is the oxygen lone pair orbital parallel to the molecular plane. (14) The present results indicate that, in contrast to the above reports, H2CO does not adsorb molecularly on Ru(110) at 80 K. At coverages ~ 1 monolayer, H2CO dissociates on Ru(110). Work function data, TPD results, and UPS spectra for coadsorbed hydrogen and CO sequentially adsorbed on Ru(110) differ sufficiently from those for H₂CO on Ru(110) that simple dissociation may not be the only process occurring; the results suggest the formation of a surface complex. At coverages > 1 monolayer, multilayer formation of molecular HoCO is observed.

Emphasis in the following discussion is on the UPS results; the TPD data will be presented in detail later. Particular emphasis is placed on the character of the H₂CO-derived complex.

II. EXPERIMENTAL PROCEDURE

The substrate was a single crystal of Ru(\sim 11 mm x 10 mm x 0.5 mm) cut with its faces parallel to the 110 plane within \pm 1/2°. The sample could be cooled to 80 K and resistively heated to more than 1550 K. The temperature is monitored by a 3% Re/W-25% Re/W thermocouple spotwelded to the back of the

crystal. The crystal was cleaned by heating in 0_2 , followed by flashing to 1550 K. This procedure has been demonstrated using AES to produce clean $\mathrm{Ru}^{\left(15\right)}$ and was verified for this crystal in a separate vacuum system.

The formaldehyde was prepared by the method of Yates, et. al. (9) and stored in a previously baked, mostly glass enclosure. Daily checks of its purity were made with the mass spectrometer. The exposures of all gases are based on measured areas of plots of mass spectrometer ion current vs. time. Hydrogen exposures were corrected for the known ion gauge sensitivity. (16) Fomaldehyde exposures are based on doses monitored using the mass 29 signal, with the Bayard-Alpert gauge off.

The precision of work function measurements based on photoemission thresholds is + 0.05 eV.

The UHV system used in this experiment has been previously described and has a base pressure of $\sim 1 \times 10^{-10}$ Torr. (17) The electrons are excited by He I radiation (hv = 21.2 eV) from a windowless microwave discharge lamp and are measured by a three-grid hemispherical retarding field energy analyzer with a collection solid angle of $\sim 0.6~\pi$ steradians and a resolution of 0.12 eV at 20 eV. (17) The typical experimental mode was as follows: (a) flash the sample clean at 1550 K, (b) measure its work function from the photoelectric threshold to check for cleanliness during the two minutes of cooling time to 80 K, (c) expose to a gas while monitoring the appropriate mass peak, (d) measure the UPS spectrum, and (e) heat the sample with an appropriate nearly linear temperature ramp while measuring the total pressure and the TPD of a mass peak of interest.

III. RESULTS

A. Work Function Changes for H_2 CO and H_2 + CO Adsorbed at 80 K The measurement of work function changes during adsorption is a useful monitor of charge transfer in the adsorbed layer on the surface. The work function of clean Ru(110) was found from the photoelectric threshold in repeat experiments to be 5.05 ± 0.10 eV. The lower solid curve in Fig. 1 is a plot of the surface work function change ($\Delta \phi = \phi_{\rm covered} - \phi_{\rm clean}$) as a function of exposure to H₂CO at 80 K. The work function change rises to a maximum (~ 0.3 eV) at low exposures. For higher exposures, $\Delta \phi$ shows a negative slope and decreases to a saturation value above 5 L (1 L = 1 Langmuir = 1 x 10^{-6} Torr-sec). The limiting value of $\Delta \phi = -0.55$ eV is characteristic of an H₂CO multilayer on Ru(110). These $\Delta \phi$ versus exposure data are very similar to results obtained previously for H₂CO adsorption on W(111) and W(100). (9) There, also, $\Delta \phi$ increased at low exposures and achieved negative values at high exposures.

For comparison, we include in Fig. 1 a plot of changes in $\Delta \phi$ when a monolayer of hydrogen on Ru(110) at 80 K ($\Delta \phi$ = 0.5 eV) is exposed to increasing doses of CO. The present data, in conjunction with the unpublished data of Sandstrom, et al., (18) indicate that $\Delta \phi$ passes through a shallow minimum at low exposures, and rises to a limiting value of $\Delta \phi$ = 0.7 eV at high exposures, when the surface is saturated with H₂ + CO. At 80 K, CO displacement of adsorbed hydrogen from the surface is slight, but preadsorption of CO allows only minimal amounts of hydrogen to adsorb subsequently. The limiting value of $\Delta \phi$ for the H₂ + CO saturated surface is between the value $\Delta \phi \stackrel{>}{\sim} 1.0$ eV observed for a CO monolayer and that seen for adsorbed hydrogen. A minimum in a plot of $\Delta \phi$ vs. CO exposure has also been seen for the average work function change of a hydrogen covered Ru field emitter (19) at 300 K.

The data of Fig. 1 suggest the possibility that adsorbed H_2^{CO} and sequentially adsorbed hydrogen and CO exhibit similar surface dipole characteristics at low exposures (and low coverages), since the sign of $\Delta \phi$ is the

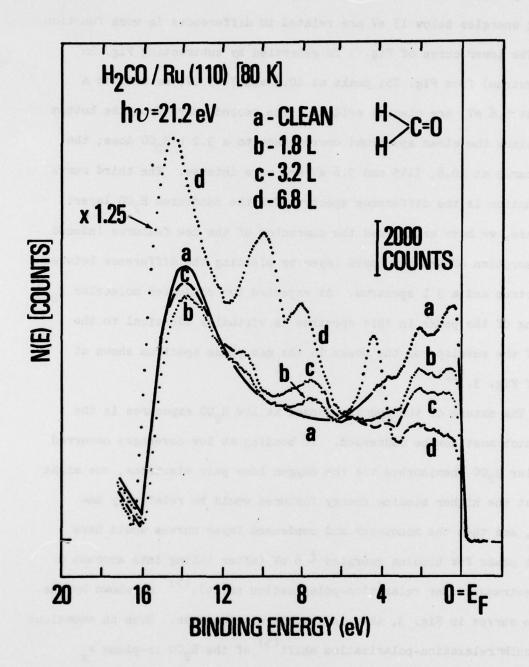
same in both cases. At higher exposures, however, the decrease in $\Delta \phi$ for adsorbed H₂CO suggests that simple dissociation into coadsorbed hydrogen + CO would no longer occur. It has been suggested previously for H₂CO on W(100) and W(111)⁽⁹⁾ that such work function behavior might arise for H₂CO dissociation at low coverages, with the formation of a surface complex or undissociated H₂CO at higher exposures. Indeed, the UPS results for a saturation coverage of H₂CO on Ru(110) discussed in Section III.B. indicate the presence of molecular H₂CO, but its existence may not be the complete explanation of the work function variation with H₂CO exposure. This variation in $\Delta \phi$ may also involve the population of different surface bonding sites: a "smoothing" effect at low coverages as the (110) trough sites are filled, followed by adsorption at sites atop the (110) ridges. Whatever the reasons for the detailed shape of these curves, it is clear that H₂CO for exposures > 1 L does not behave like coadsorbed H₂ + CO.

B. Ultraviolet Photoemission Spectra for H₂CO and Related Molecules Adsorbed at 80 K

A series of unsmoothed UPS spectra for H₂CO adsorbed on Ru(110) at 80 K are shown in Fig. 2 as excited by 21.2 eV radiation. For clarity, smooth curves replace the data in parts of some spectra. Curve a is the energy distribution curve for the clean Ru surface. The structure in the range 0 to 6 eV is due to photoemission from the Ru(4d,5s) band, and the region from 6 to 14 eV is relatively structureless. This is consistent with UPS data for Ru(001)⁽²⁰⁾ and Ru(100).⁽²¹⁾ Following adsorption of H₂CO doses of 1.8 L and 3.2 L, respectively, curves b and c were measured. These curves are associated with fractional monolayer coverages of H₂CO, and correspond to the labeled points of Fig. 1. In both cases, new features at ~7.5 and ~11 eV are seen for higher exposures. The intense spectrum of curve d exhibits new features unlike those of curves b and c, and appears to be

Fig. 2. Unsmoothed UPS spectra (hv = 21.2 eV) for clean Ru(110) (curve a) and for increasing formaldehyde exposures on Ru(110) at 80 K (curves b-d).

The exposures are indicated on the figure. Each spectrum required 8 scans of 256 channels, 0.2 sec/channel.



characteristic of a condensed H2CO layer (point d, Fig. 1).

The chemisorption-induced features in the UPS spectra of Fig. 2 are more clearly seen in the UPS difference spectra shown in Fig. 3; features at binding energies below 13 eV are related to differences in work function values. The lower curve of Fig. 3 is generated by subtracting Fig. 2a (clean spectrum) from Fig. 2b; peaks at 10.8 and 7.45 eV, as well as a shoulder at 5.6 eV, are clearly evident. The second curve from the bottom (Fig. 2c minus the clean spectrum) corresponds to a 3.2 L H₂CO dose; the three features at 10.8, 7.45 and 5.6 eV are more intense. The third curve from the bottom is the difference spectrum for the condensed H₂CO layer; in this case, we have emphasized the character of the new features induced by the adsorption of the condensed layer by plotting the difference between a 7 L spectrum and a 3 L spectrum. As expected for condensed molecular H₂CO, the spacing of the peaks in this spectrum is virtually identical to the spacing of the envelope of the peaks in the gas phase spectrum shown at the top of Fig. 3. (22)

The nature of the species formed at low H₂CO exposures is the problem which must now be addressed. If bonding at low coverages occurred as molecular H₂CO chemisorbed via the oxygen lone pair electrons, one might expect that the higher binding energy features would be relatively unperturbed, and that the monolayer and condensed layer curves would have coincident peaks for binding energies \$\frac{1}{2}\$ 6 eV (after taking into account a constant extramolecular relaxation-polarization shift). As shown by the difference curves in Fig. 3, this is clearly not the case. Even an anomalous extramolecular relaxation-polarization shift (5) of the H₂CO in-plane \$\pi_{\text{X}}\$ orbital (the highest B.E. peak in the HeI gas phase spectrum) for chemisorbed molecular H₂CO cannot be invoked to argue that chemisorbed, molecular H₂CO

is adsorbed at 80 K on Ru(110). We conclude from Fig. 3 that H₂CO is not molecularly adsorbed in the submonolayer coverage range, and suggest that low coverage H₂CO is, to a large extent, dissociated.

In order to shed light on the nature of the HoCO decomposition products, we compare in Figure 4 the UPS difference spectrum for a 1.8 L H2CO dose on Ru(110) with difference spectra for coadsorbed hydrogen + CO, adsorbed CO alone, and adsorbed hydrogen alone on Ru(110). The adsorption of a saturation coverage of hydrogen results in the appearance of two peaks at 5.6 and 1.65 eV below $E_{\rm p}$, as well as selective attenuation of the Ru valence band. The CO difference spectrum shows the characteristic two-peaked structure observed for the chemisorption of molecular CO on many surfaces and in particular, other faces of Ru; (20,21) the peak at 10.6 eV is due to the CO 4σ level, and the peak at 7.5 eV is due to a combination of the 5σ and 1π levels. Curve 4b corresponds to coadsorbed hydrogen + CO on Ru(110); a saturation hydrogen layer was exposed to a 1.2 L dose of CO. It exhibits four features which have peak energies within 0.1 eV of those found in the separate hydrogen and CO spectra. Curve 4a corresponds to a fractional monolayer coverage (1.8 L dose) of H2CO. This H2CO spectrum is quite different from that of molecular H2CO (Fig. 3) and similar to the coadsorbed ${\rm H}_{\rm o}$ + CO spectrum (Fig. 4b), indicating that a major portion of the adsorbed H2CO is dissociated. However, there are two notable differences between Figs. 4a and 4b. Firstly, the peak at 10.8 eV in the HoCO spectrum is broader than and is shifted by ~ 0.3 eV with respect to the corresponding feature in the H2 + CO curve. Secondly, the strong peak at 1.65 eV, related to hydrogen adsorption in the H₂ + CO spectrum, is not evident in the HoCO spectrum. These differences appear more significant in light of the thermal behavior of adsorbed HoCO.

Fig. 3. UPS spectrum for gas phase formaldehyde (Ref. 22) and unsmoothed difference spectra [N(E)] for H₂CO adsorbed on Ru(110) at 80 K (h_V = 21.2 eV). The upper gas phase photoelectron spectrum is referenced to the ionization potential (I.P.) relative to the vacuum level. The multilayer curve is the difference between UPS spectra for a 7 L and a 3 L H₂CO exposure on Ru(110) at 80 K. Curves labeled (c-a) and (b-a) refer to the difference spectra for the data shown in Fig. 2.

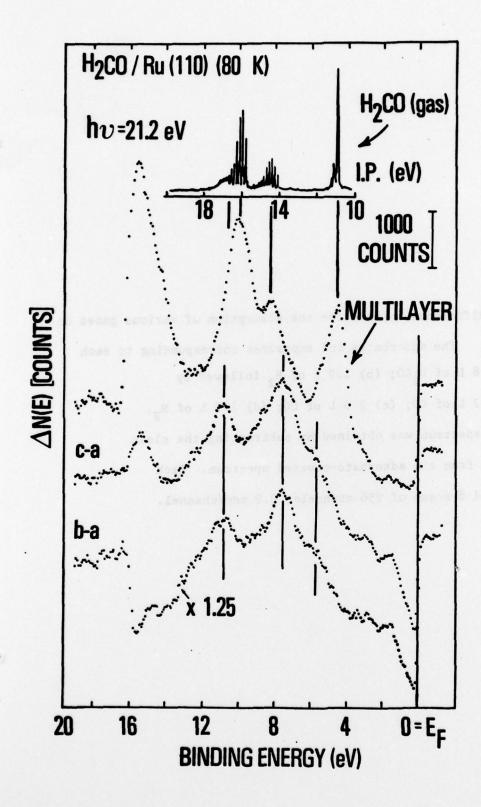
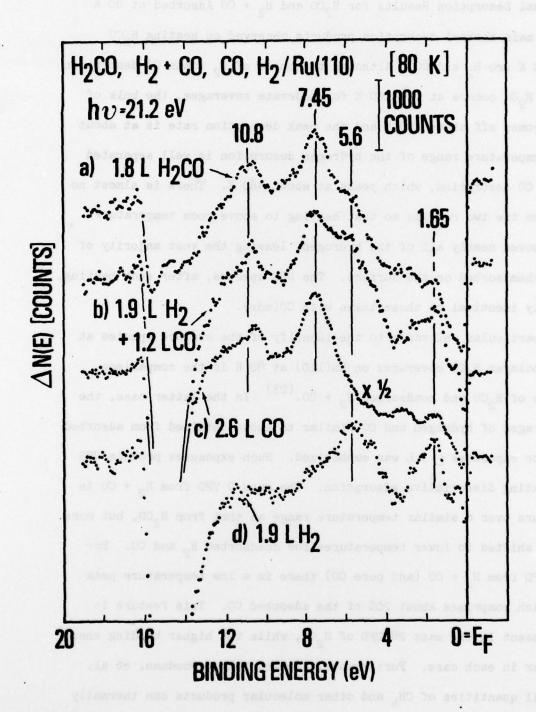


Fig. 4. Unsmoothed UPS difference spectra for the adsorption of various gases on Ru(110) at 80 K. The adsorbates and exposures corresponding to each curve are (a) 1.8 L of H₂CO; (b) 1.9 L of H₂ followed by adsorption of 1.2 L of CO; (c) 2.6 L of CO; (d) 1.9 L of H₂.

adsorption of 1.2 L of CO; (c) 2.6 L of CO; (d) 1.9 L of H₂.

Each difference spectrum was obtained by subtracting the clean surface spectrum from the adsorbate-covered spectrum. Each spectrum required 8 scans of 256 channels, 0.2 sec/channel.



C. Thermal Desorption Results for H_2 CO and H_2 + CO Adsorbed at 80 K

The main thermal desorption products observed on heating H_2^{CO} adsorbed at 80 K are H_2 and CO. Although the onset of H_2 (mass 2) desorption from adsorbed H_2^{CO} occurs at $T^{\frac{1}{2}}$ 100 K for moderate coverages, the bulk of the hydrogen comes off above 200 K and the peak desorption rate is at about 270 K. The temperature range of the hydrogen desorption is well separated from that for CO desorption, which peaks at about 460 K. There is almost no overlap between the two regions so that heating to above room temperature (\sim 330 K) removes nearly all of the hydrogen, leaving the vast majority of the CO still chemisorbed on the surface. The UPS spectra, after such heating, are essentially identical to those taken with CO(ads).

Of particular relevance to the identify of the surface species at fractional monolayer H₂CO coverages on Ru(110) at 80 K is the comparison of TPD studies of H_2 CO and coadsorbed H_2 + CO. (23) In the latter case, the study of coverages of hydrogen and CO similar to those obtained from adsorbed H2CO layers for exposures < 3 L was emphasized. Such exposures produce UPS spectra indicating dissociative adsorption. The mass 2 TPD from H2 + CO in this case occurs over a similar temperature range as that from HoCO, but more desorption is shifted to lower temperatures for coadsorbed H, and CO. For the mass 28 TPD from H2 + CO (and pure CO) there is a low temperature peak (\sim 150 K) which comprises about 20% of the adsorbed CO. This feature is essentially absent in the mass 28 TPD of HoCO, while the higher binding energy peak is similar in each case. Furthermore, the results of Goodman, et al. show that small quantities of CH, and other molecular products can thermally desorb from a fractional H2CO monolayer on Ru(110) adsorbed at about 300 K, (3,4) but cannot be produced by thermal desorption of coadsorbed hydrogen + CO. Thus, as with the UPS results, there are rough similarities and more subtle

differences between the TPD of H_2 + CO and H_2 CO adsorbed on Ru(110). There is an attractive interaction which holds some portion of the hydrogen and CO on the surface to higher temperatures than is the case for a coadsorbed layer of H_2 + CO. This suggests the possibility of a surface molecular complex existing for at least some of the dissociated H_2 CO, but it is not possible to assess the importance of other factors such as differences in binding sites for the two situations.

IV. DISCUSSION

In the spectral region between 4 and 12 eV below E_F in Figure 3, CO adsorbed at low coverages at 80 K produces a species whose UPS difference spectrum is distinct from molecular formaldehyde. In contrast, although several molecular orbitals of chemisorbed H₂CO on ZnO were perturbed by the interaction with the surface, (5) the molecular character of the adsorbate was demonstrable. However, the distortion of the UPS spectrum is so great on the Ru(110) surface that using the H₂CO molecular orbital structure as a "finger-print" is not useful. In fact, we conclude that low coverages of H₂CO dissociate on the Ru(110) surface at 80 K; H₂CO is the first organic molecule incorporating oxygen which has been observed using UPS techniques to dissociate at such low temperatures on a metal. At somewhat higher temperatures, between 100 K and 120 K, we note that carbon-carbon bond scission is reported to occur upon the adsorption of C₂H₂ and C₂H₄ on the clean α-Fe(100) surface. (24)

In contrast to its low exposure behavior on Ru(110), for high exposures of H_2^{CO} the surface with a saturated work function value of $\Delta \phi = -0.55$ eV exhibits peak molecular orbital energies with such a clear resemblance to those of the gas phase photoelectron spectrum of H_2^{CO} that we conclude this layer contains pure molecular H_2^{CO} .

The question of the nature of the dissociated species of adsorbed H2CO at 80 K remains. If we are to use the "fingerprint" method of identification,

the overall similarities between the fractional monolayer formaldehyde spectrum and a spectrum produced by coadsorption of hydrogen + CO is compelling (Fig. 4). Although the relative intensities do not match exactly, the strong peak at 7.5 eV and a lesser one in the 10.8 eV region are suggestive that a CO bond exists with the carbon atom bonded to the surface. The presence of a shoulder at 5.6 eV coincides with the dominant hydrogen-related feature. In addition, the $\Delta \phi$ values for very low formaldehyde coverages and coadsorbed hydrogen + CO are both positive (indicating electronegative species; cf. Fig. 1), and differ by as little as 0.15 eV. Furthermore, the gross features of the desorption of H_2 and CO from H_2 CO are quite similar to those of H_2 + CO.

From the UPS results the dominant impression is certainly that low coverage adsorbed H_2^{CO} looks like H_2 + CO. However, the differences we observe between the two, although small, may be important in light of the TPD and work function change data. The feature at 1.65 eV in both the H_2 and H_2 + CO UPS curves is absent in any strength in the H_2^{CO} curve (Fig. 4). This feature is also absent following heating of adsorbed H_2^{CO} or CH_3^{CO} layers on Ru(110) to $\stackrel{>}{\sim}$ 200 K, where one would expect complete dissociation to coadsorbed H_2 + CO. (It should be cautioned that the dependence of this feature on hydrogen coverage in the presence of CO is not known.) We have also noted that there is a difference in the separation of the main peaks (\sim 0.3 eV) and a broader, more symmetric shape to the 10.8 eV features in the H_2^{CO} spectrum, when compared to corresponding features in the H_2 + CO spectrum or the CO spectrum.

The thermal desorption studies also exhibit differences between $\rm H_2CO$ and $\rm H_2$ + CO in a shift of hydrogen binding states to higher energy and the absence of the low temperature CO peak in the TPD of adsorbed $\rm H_2CO$.

The differences in $\Delta\phi$ for H_2^{CO} and H_2^{+} CO in the later stages of monolayer formation (2-4 L, Fig. 1) indicate the presence of different surface species in the two cases. The possibility of an H_2^{CO} -derived complex is suggested, but its concentration cannot be estimated from these data.

In conclusion, H_2^{CO} is observed to adsorb dissociatively on Ru(110) at 80 K. The work function and TPD data, supported by subtle changes in the UPS spectra, suggest that the H_2^{CO} -derived surface species are not solely identified with coadsorbed hydrogen + CO. At least a portion of the H and CO present on the surface is interacting differently than in a H_2 + CO layer. This may indicate the existence of a surface molecular complex, but a better description of this interaction must await additional surface spectroscopic measurements.

V. ACKNOWLEDGMENT

The authors wish to acknowledge the Surface and Electron Physics Section of NBS and in particular B. J. Waclawski for the use of the photoemission apparatus described herein. The authors thank D. R. Sandstrom, T. V. Vorburger, and B. J. Waclawski for granting their permission to use their unpublished data in Figure 1. We also thank D. W. Goodman for discussions which were always stimulating, and we gratefully acknowledge the assistance of K. Revesz in the data analysis. This work was supported by the Office of Naval Research.

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